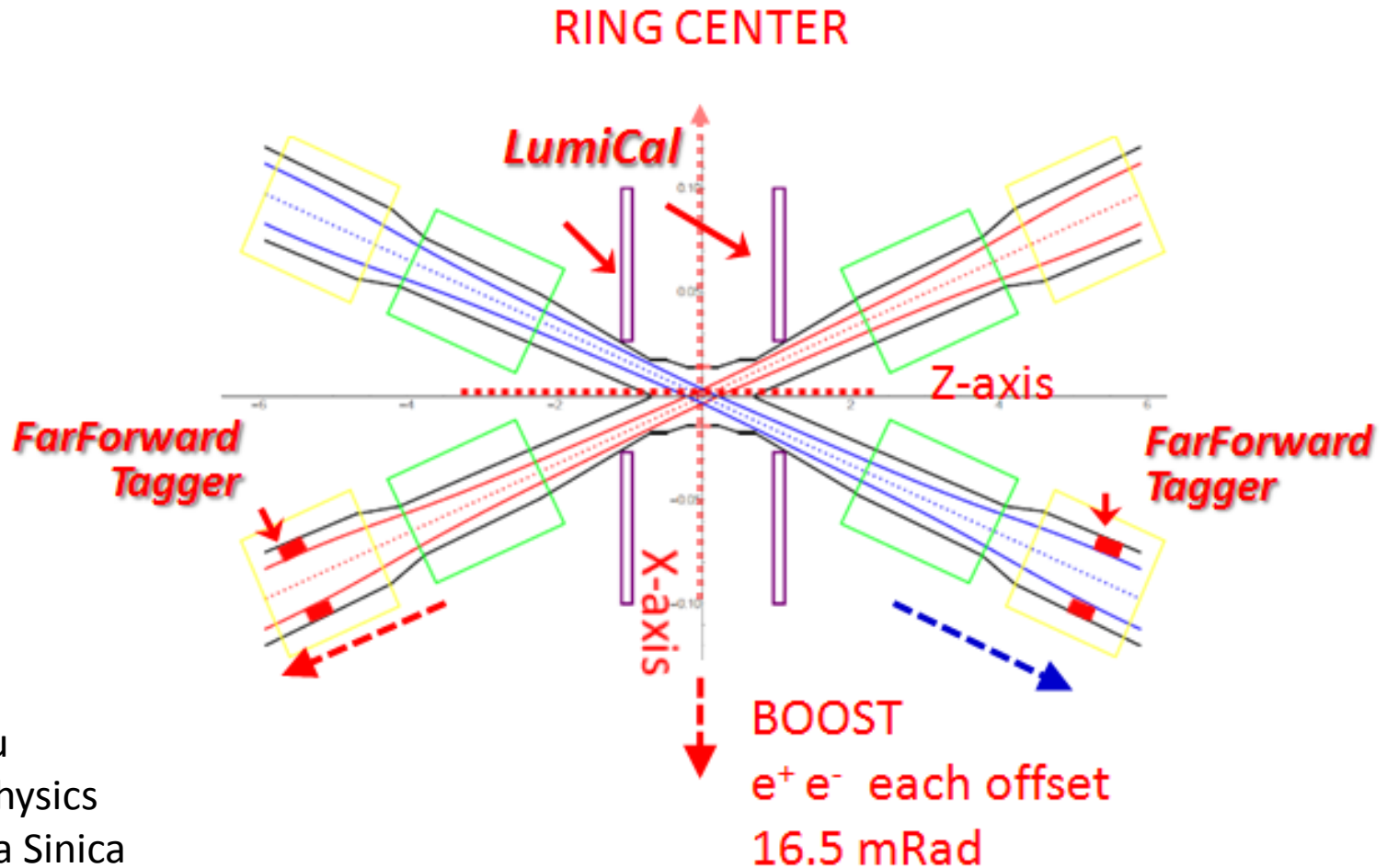


LumiCal Design Status



Suen Hou
Inst. of Physics
Academia Sinica

2020.05.29

<https://indico.ihep.ac.cn/event/11801/>

Outline

- **Physics basic, BHLUMI :**

estimating Bhabha cross section for geom acceptance

beam crossing boost effect

→ Pushing for $\theta_{\min} < 30 \text{ mRad}$ for $\sigma(\text{Bhabha}) > 50 \text{ nb}$



- **GEANT study: reality toward $\delta L/L \sim 10^{-4}$**

beampipe material → multiple scattering, EM shower

beampipe shape, detector position → spatial resolution



- **LumiCal + : Geometry and detector coverage**

Vertex Si volume : wafer surrounding beampipe

beampipe Flange : Si disks + LYSO Calorimeter

Q-pole front : LumiCal calo using LYSO 2x2 mm² bars

outgoing beampipe : Far-Forward Tagger

Luminosity measurement

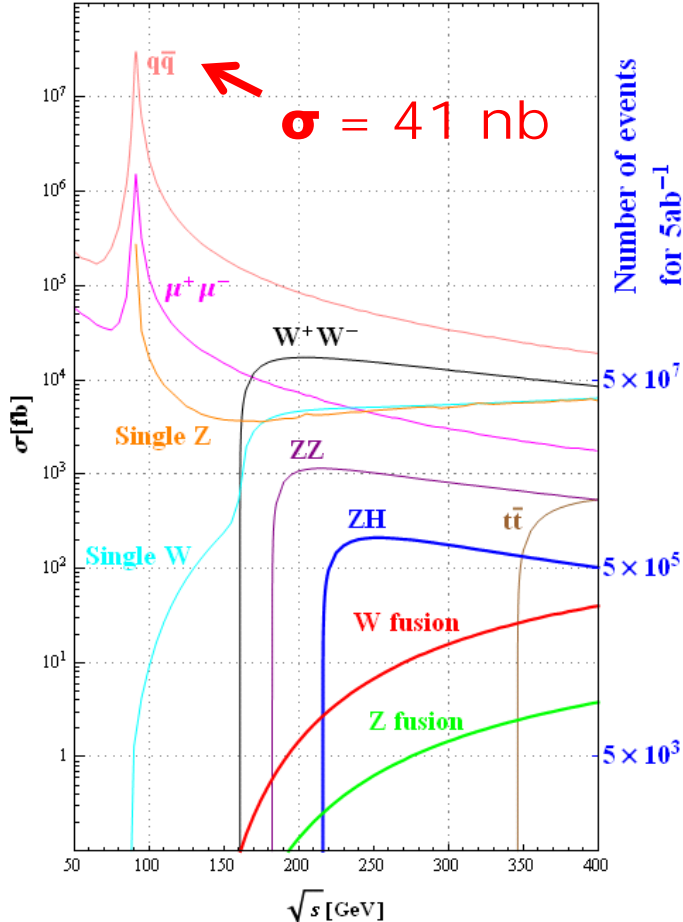
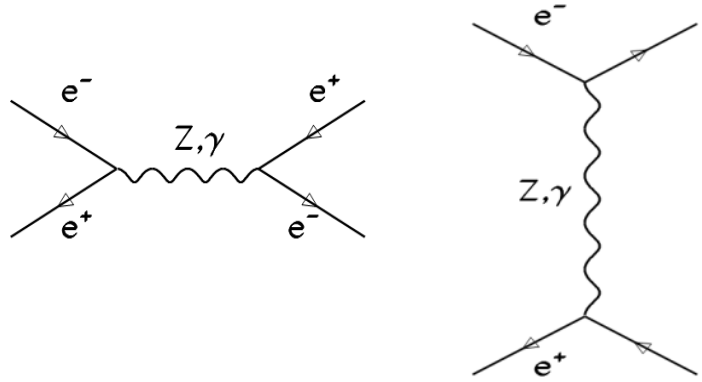
- Reference to Z-lineshape, $e^+e^- \rightarrow Z \rightarrow q\bar{q}$
- Luminosity of e^+e^- collisions by measuring Bhabha elastic scattering

$$e^+e^- \rightarrow e^+e^-$$

- QED process, theoretical < 0.1% precision
- triggering on a pair of scattered e^+e^-

$$\mathcal{L} = \frac{1}{\epsilon} \frac{N_{\text{acc}}}{\sigma^{\text{vis}}} \quad \sigma = \frac{16\pi\alpha^2}{s} \left(\frac{1}{\theta_{\text{min}}^2} - \frac{1}{\theta_{\text{max}}^2} \right)$$

LO diagrams



Luminosity precision

Dominant systematic error

$$\delta L/L \sim 2 \delta\vartheta/\vartheta_{\min}$$

For a precision of $\delta L/L < 10^{-3}$

LumiCal at $z = \pm 1$ m, $\rightarrow \theta_{\min} = 30$ mRad

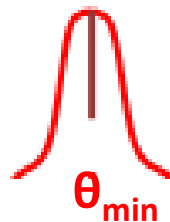
$\rightarrow \delta\vartheta = 15 \mu\text{Rad}$ or $dr = 15 \mu\text{m}$

Error due to offset on Z

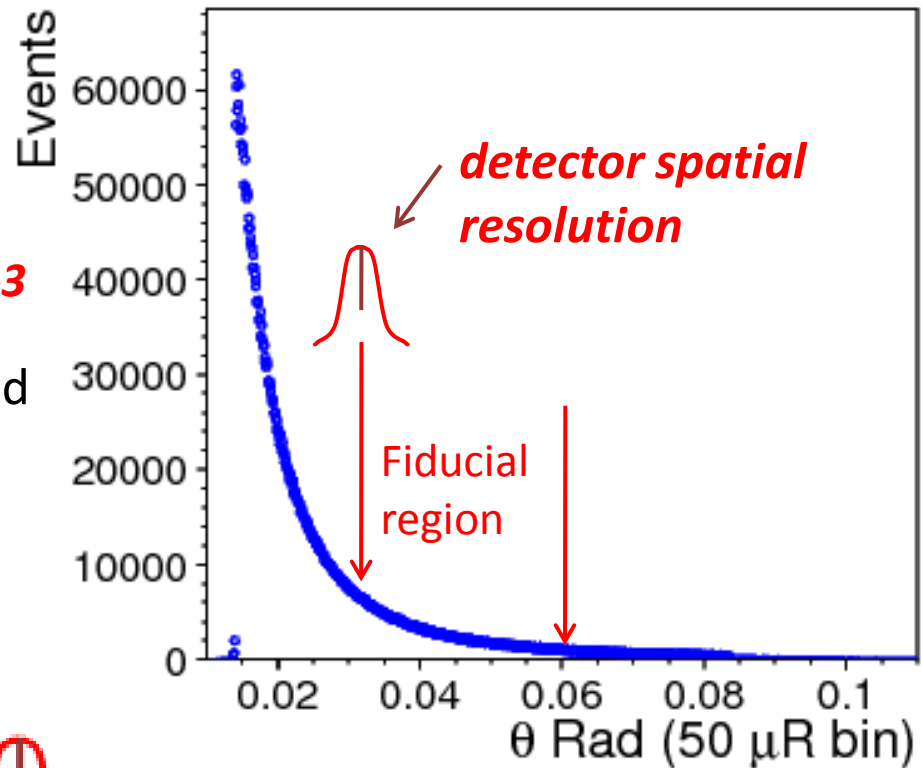
$\rightarrow 0.1$ mm on z or $dr = \delta R \times \vartheta = 3 \mu\text{m}$

LumiCal design goal:

- Spatial res. narrow
- “Standard error of the mean”
on θ_{\min} : $\sigma/\sqrt{N} < 1$ mRad



Bhabha ϑ -angle distribution



offset of fiducial edge
to “the mean on θ_{\min} ”
 \rightarrow **LUMINOSITY error**

Bhabha detection

- $e^+e^- \rightarrow e^+e^-$ elastics scattering

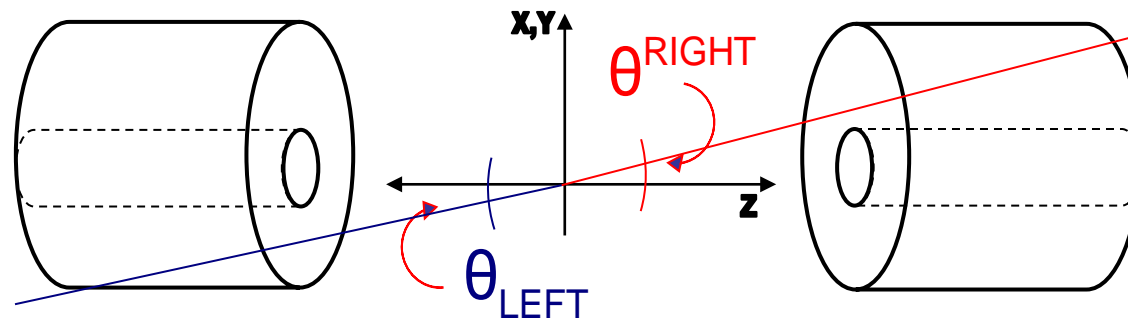
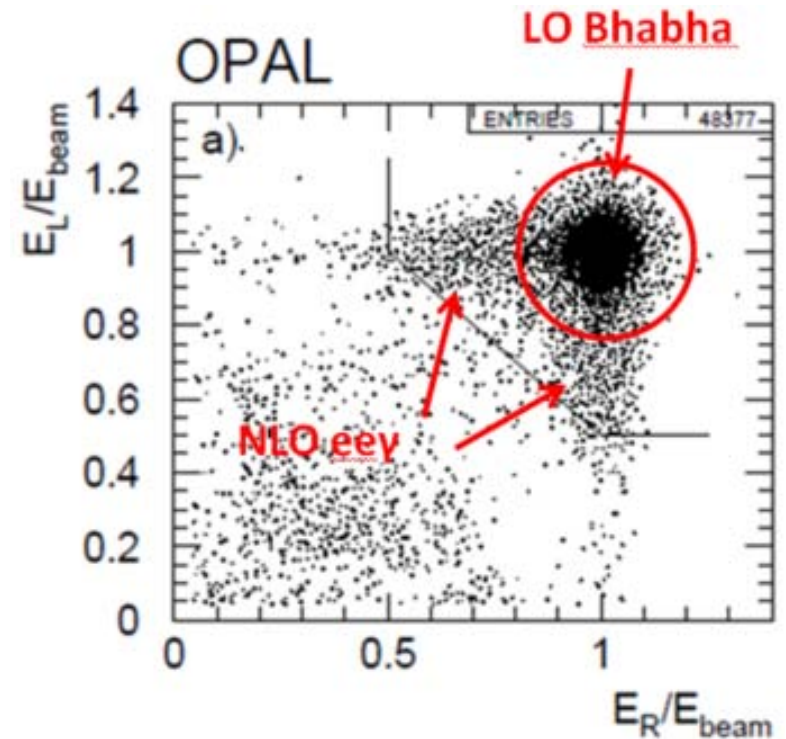
Event signature

1. $E(e^\pm) = E_{\text{beam}}$
2. e^+ , e^- Back-to-Back

- **NLO $e^+e^- \rightarrow e^+e^- \gamma$**

~1% events

1. e^+ , e^- approximately Back-to-Back
2. one electron $E' < E_{\text{beam}}$
3. Detector e/γ ID, spatial resolution



$$\Delta\theta \equiv \theta_{\text{RIGHT}} - \theta_{\text{LEFT}}$$

Study with BHLUMI

- Bhabha cross section
- 33 mRad beam crossing
 - boosted $e\bar{e}\gamma$ distribution

BHLUMI theoretical precision

Bhlumi 4.04 writeup: CERN-TH/96-158

cds.cern.ch/record/310621/files/th-96-158.ps.gz

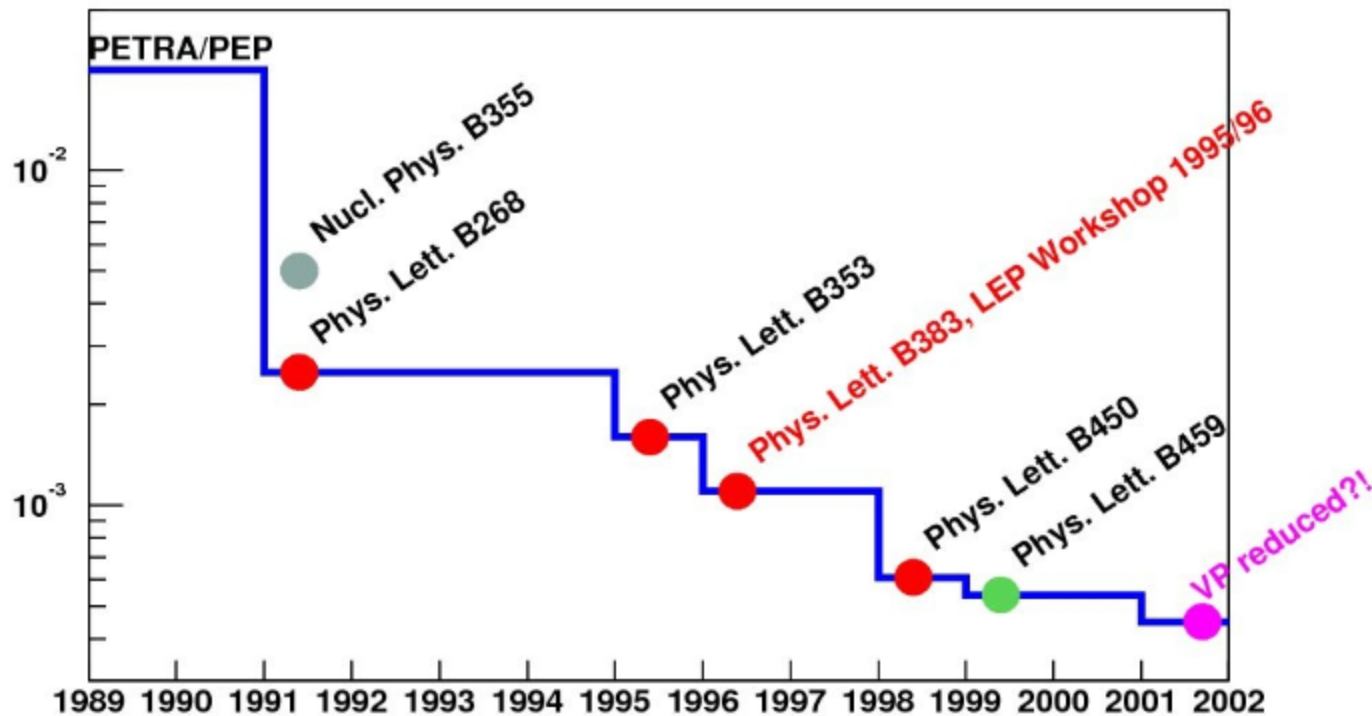
http://cern.ch/~jadach/public/Bhlumi-linux-4.04-export_2002.11.05.tar.gz

Theory uncertainty: 0.25% was **BHLUMI 2**, reported in CPC package paper

<http://inspirehep.net/record/321226?ln=en>

The latest **BHLUMI 4** report is pushed to **< 0.1%**

Evolution of luminosity theoretical error at LEP1



Reproduce BHLUMI to 0.1%

Bhlumi-linux-4.04-export_2002.11.05.tar.gz

Compiled by g77 on SL6, **demo.f** produce numbers as in paper

CERN-TH/96-158

**BARE1: $.024 < \theta_1', \theta_2' < .058$
 $s' > 0.5s$**

```
0.1000 0.252000E+03 *****
|||||
Xsec_BARE1 = 169.19520371 Nanob.
error      = 0.67481969 Nanob.
Xsec_CALD2 = 136.21881786 Nanob.
error      = 0.64151939 Nanob.
|||||
suen@bheui034:~/work/bhlumi/csrc/demo$
```

LEP workshop95 on Bhabha established 0.1% precision

Hep-ph/9602393

demo.f

1000000 ev

KeyPia=0, KeyZet=0

CMS = 92.3 GeV

Xsec_BARE1 = **162.5295** Nanob.

Error = 0.2061 Nanob.

```
|||||
User should cross-check the following two output cross sections
which are calculated and printed at the very end of the output:
Workshop95, Table14, BARE1 WW for zmin=0.5: KeyGen=3, KeyPia=0, KeyZet=0
Workshop95, Table18, CALD2 WW for zmin=0.5: KeyGen=3, KeyPia=2, KeyZet=1
|||||
```

Hep-ph/9602393

Table 14: Monte Carlo results for the symmetric Wide-Wide ES's BARE1, for matrix elements beyond first order. Z exchange, up-down interference switched off. The center of mass energy is $\sqrt{s} = 92.3$ GeV. Not available x

z_{min}	BHLUMI [nb]
.100	166.892 ± .006
.300	165.374 ± .006
.500	162.530 ± .006
.700	155.668 ± .006
.900	137.342 ± .006

BHLUMI calculations

1. Theta range input : **Th1, Th2**
Xcru calculated for Thmin=0.7xTh1 to 2xTh2
2. KeyWgt=0 → event wgt=1, for simulation
count events in chosen condition
scale to Xcru

BARE1 X section: (of the bhlumi paper)

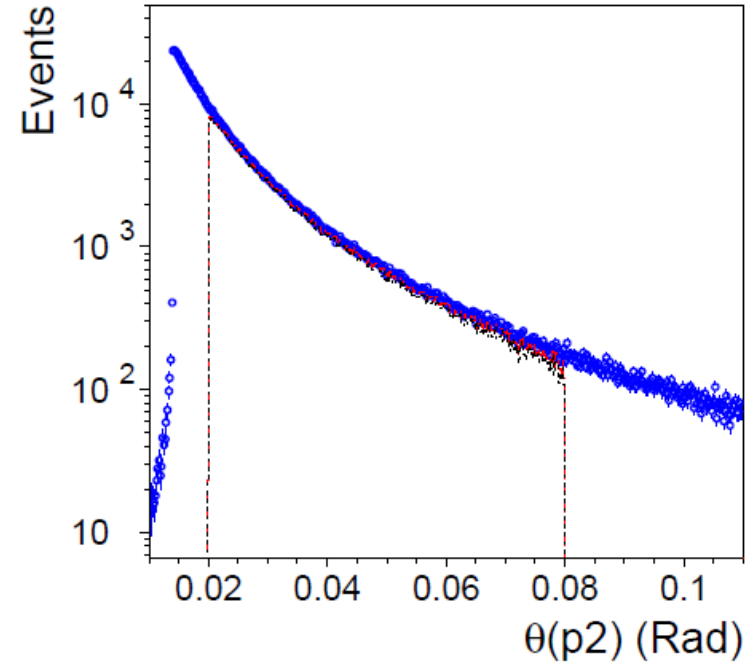
$\text{Th1} < \theta_1'$ and $\theta_2' < \text{Th2}$, $s' > 0.5s$

Use BARE1 as reference

Theoretical Error $\sim 10^{-3}$

is static, dependings on parameters →
if there will be more precise calculation
it is constant scaling

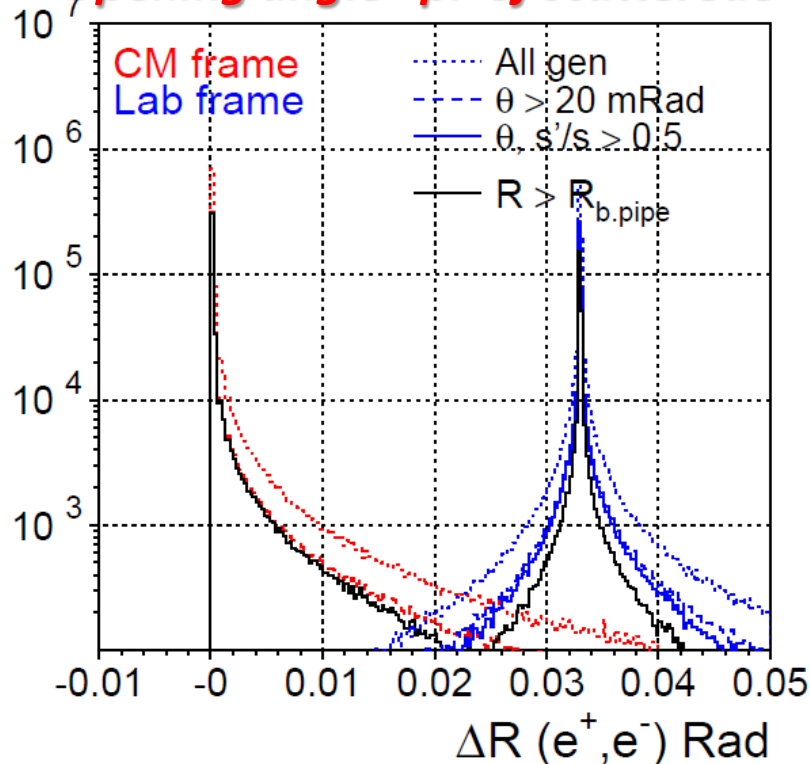
→ it does not limit us from pursuing 10^{-4}



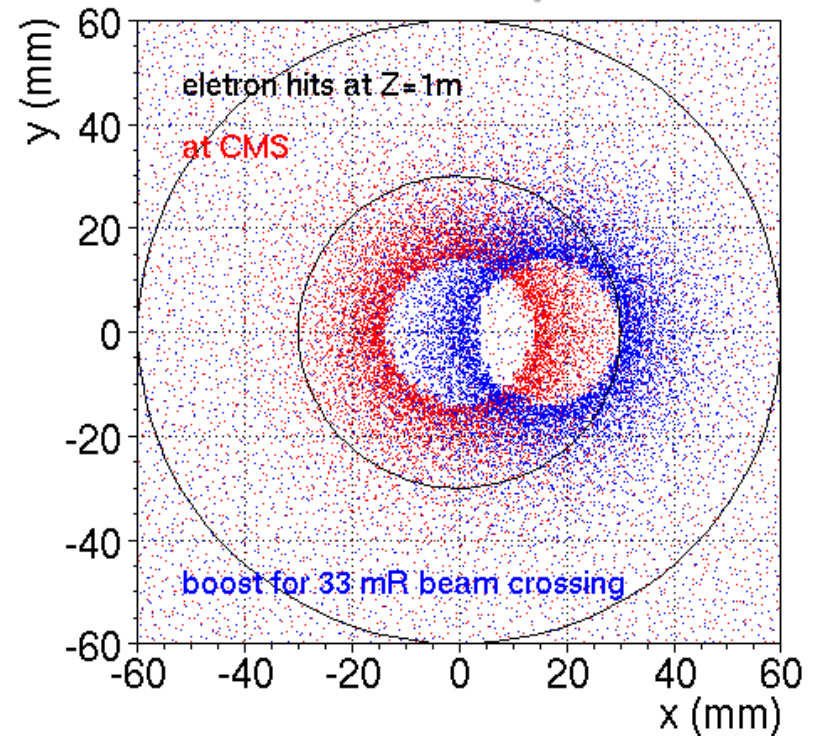
Bhabha back-to-back boosted by 33 mRad beam crossing

- Bhlumi electrons boosted for the 33 beam crossing by ~ 16.5 mRad to +x direction
- Compared for Bhabha selection conditions

Opening angle $-\pi$ of scattered e^+e^-

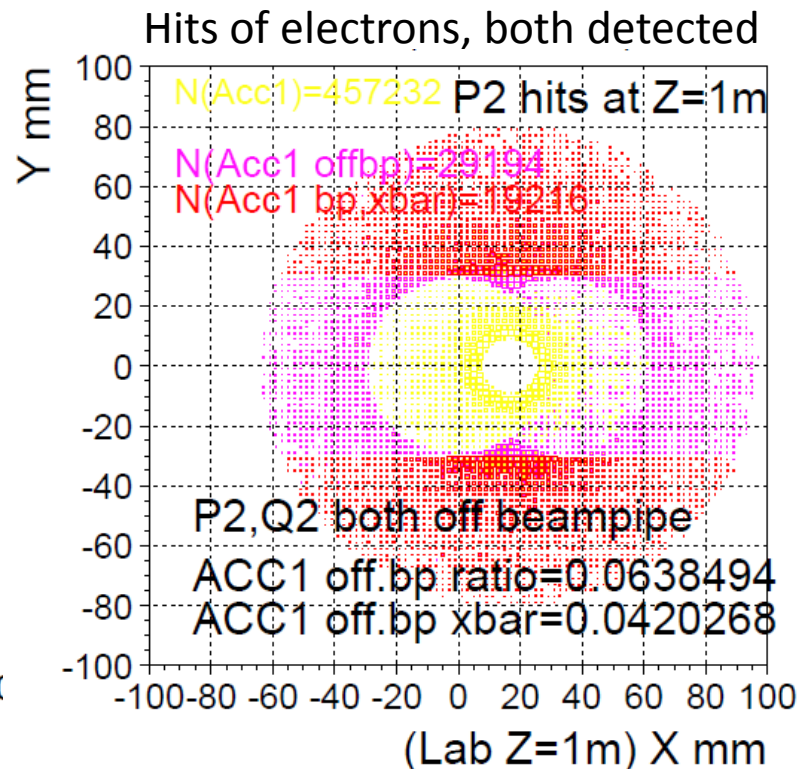
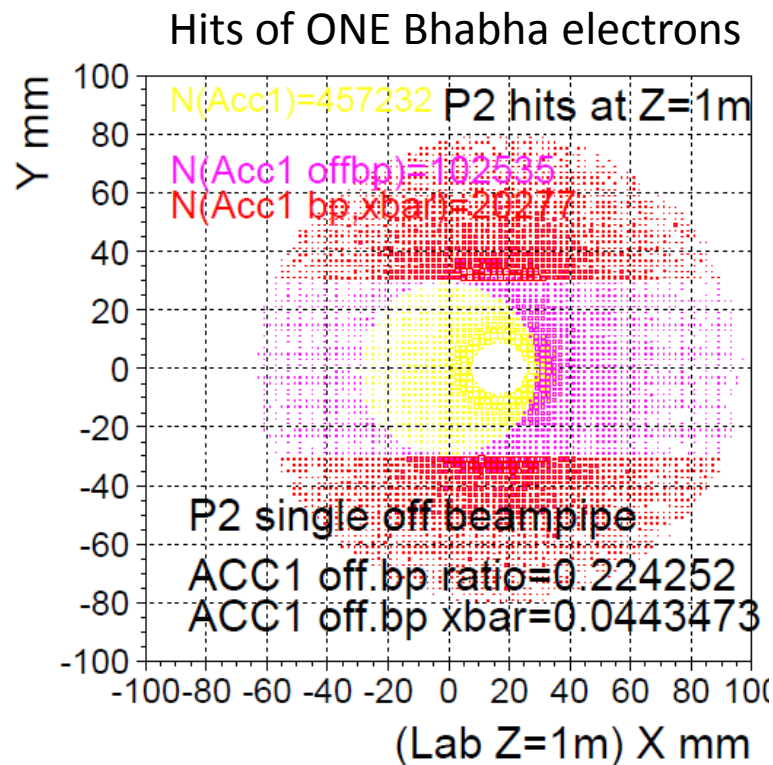


Bhabha at detector plane $Z=1m$

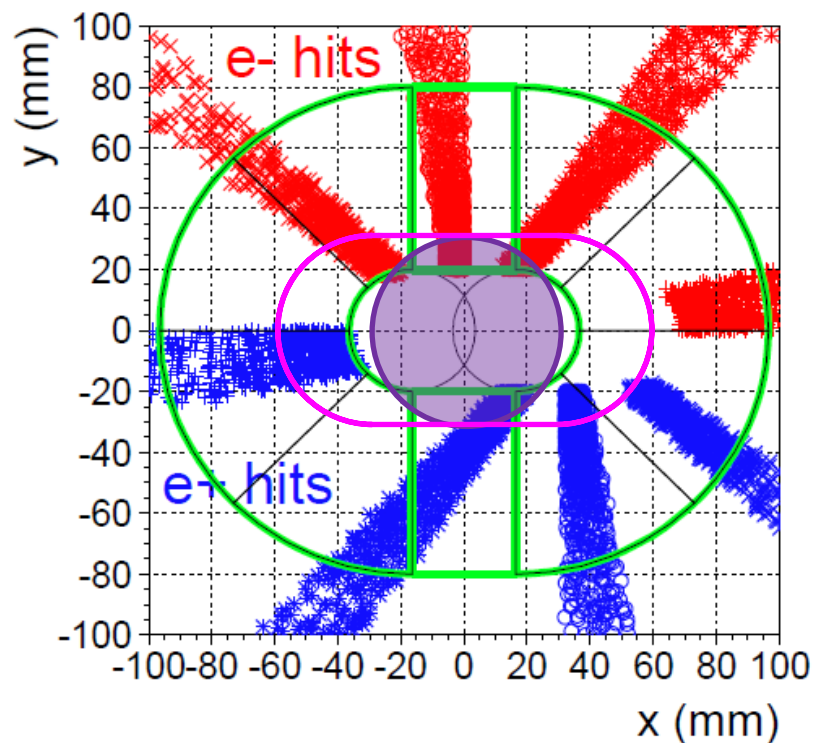
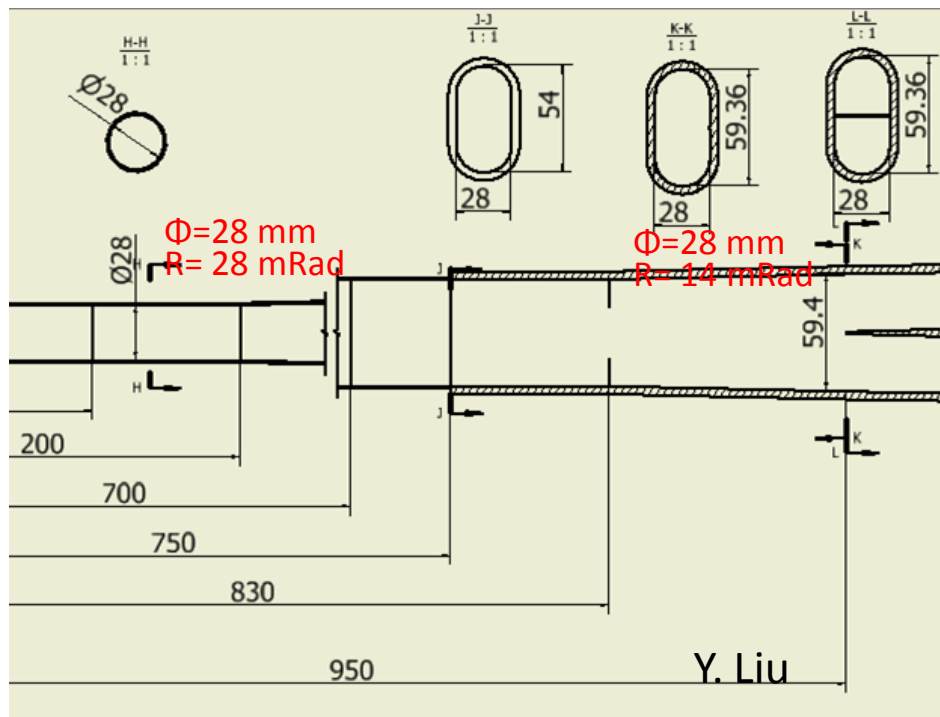


Bhabha X sec. vs Lab z-axis round pipe

- CMS generated $\text{th1}=10$ mRad \rightarrow boosted $+16.5$ mRad, $+X$ are low angle Bhabha
 - beampipe is LAB z-axis centered, **radius = 30 mRad** ($r=30\text{mm}$ @ $z=1\text{m}$)
at $x=+30$ mm, Bhabha electrons are of $\theta = 13.5$ mRad
- \rightarrow Off beam pipe, detect: **one electron (262 nb) / both electrons (74.6 nb) = 3.51**
- \rightarrow Hori. cut $\pm 30\text{mm}$: **one electron (51.8 nb) / both electrons (49.1 nb) = 1.05**



Bhabha X section



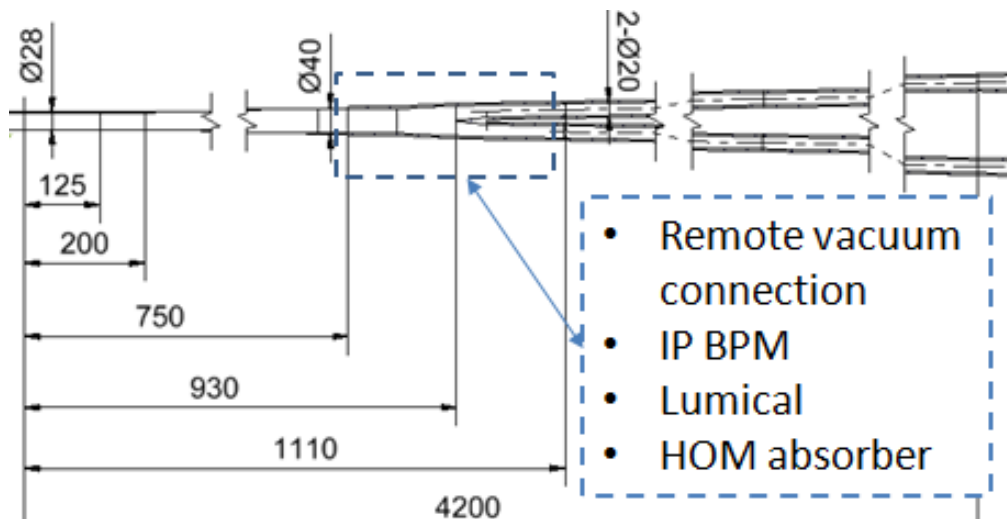
beampipe, $r=30$ mRad (vertical) $\rightarrow \sigma(\text{Bhabha}) \gtrsim 50$ nb
 ($r=30\text{mm}$ @ $z=1\text{m}$)

CMS 10 ~ 80 mRad		LAB detect ONE electron		LAB detect both electrons	
BARE1		off beampipe full phi coverage	off beampipe cut off $\pm 30\text{mm}$	off beampipe full phi coverage	off beampipe cut off $\pm 30\text{mm}$
Nevents	457232	102535	20277	29194	19216
Xsec (nb)	1168.3	262.0	51.81	74.60	49.10

Low θ Bhabha, ONE electron detected

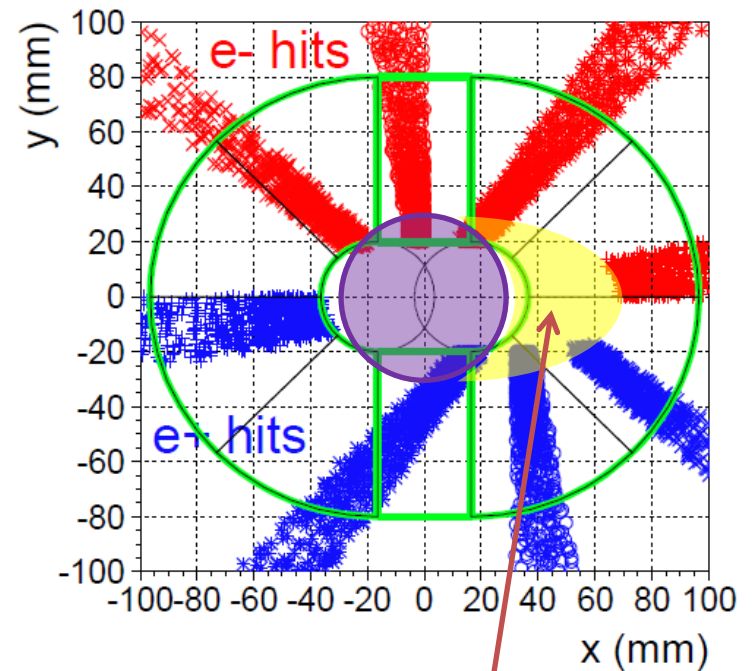
**LumiCal beampipe is round
 $\varphi = 40$ mm?**

- LOW angle Bhabha on x-axis
one electron detected (+x side)
- the other electron (-x side)
is boosted/lost into beampipe



H. Wang

- ID boosted Bhabha
by a **Far-Forward tagger**
 $10 \text{ mRad} < \theta < 30 \text{ mRad}$
for the lost electron
- σ_{Bhabha} is 5x higher



**Very hot region,
Bhabha got
boosted outward**

BHLUMI study summary

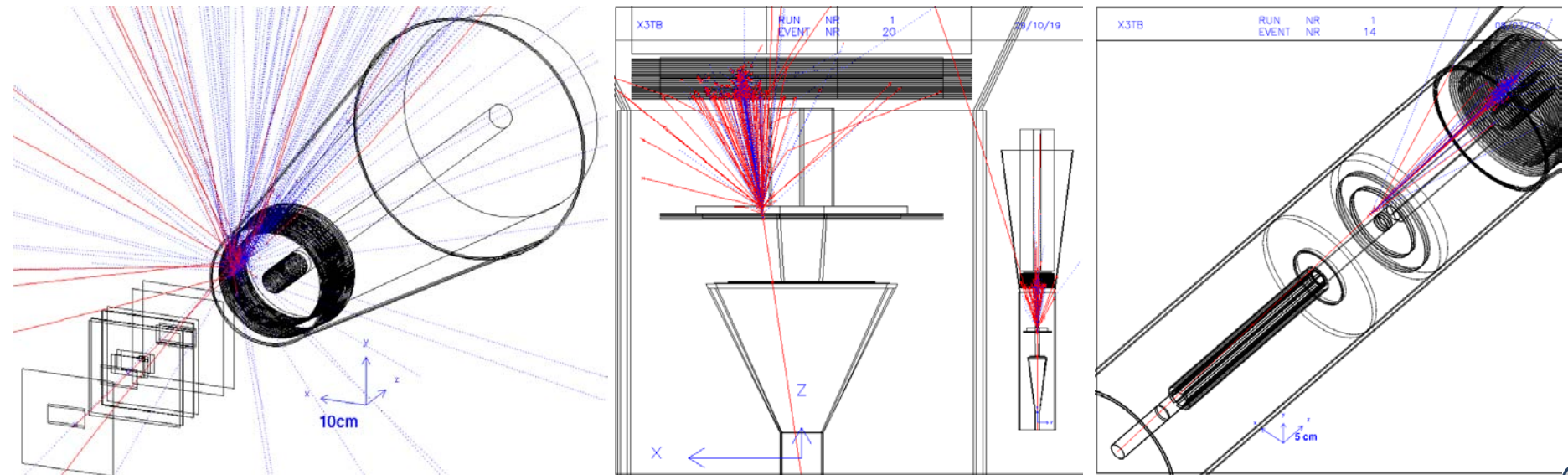
- Bhabha $\Theta_{\min} \sim 30$ mRad for ~ 50 nb
both back-to-back electrons detected
- 33 mRad beam crossing
→ LumiCal +x edge
having boosted low θ particles ($\theta \sim 16.5$ mRad)
 - ✓ x5 Bhabha cross section, ONE electron detected
 - ✓ forward physics, SM NLO, two-photon
 - add far-forward taggers
to explore this region

GEANT simulation

*Intrinsic spatial resolution
due to multiple scattering, EM shower*

LumiCal GEANT versions

- Code originated from a Si calo test-beam for lateral shower
- **Version CDR:** a SiW sandwich detector
no upstream material
- **Version post-CDR:**
a Cone shape beampipe: optimizing spatial resolution
a Tube shape close to real pipe, how to get off Mul.Scattering



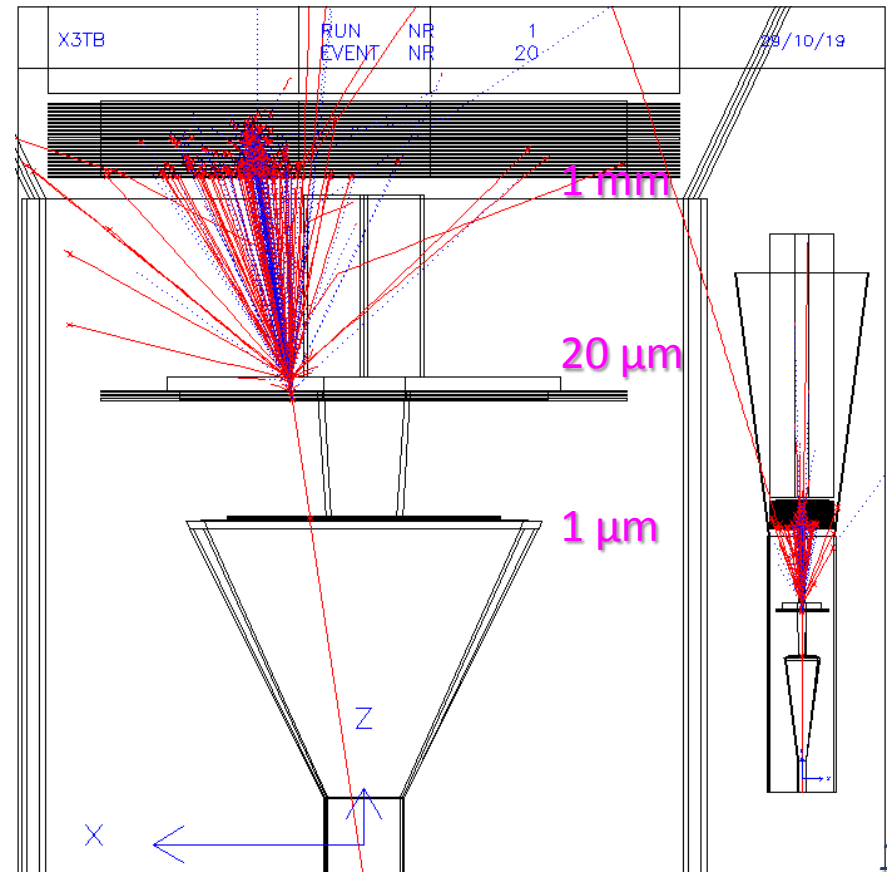
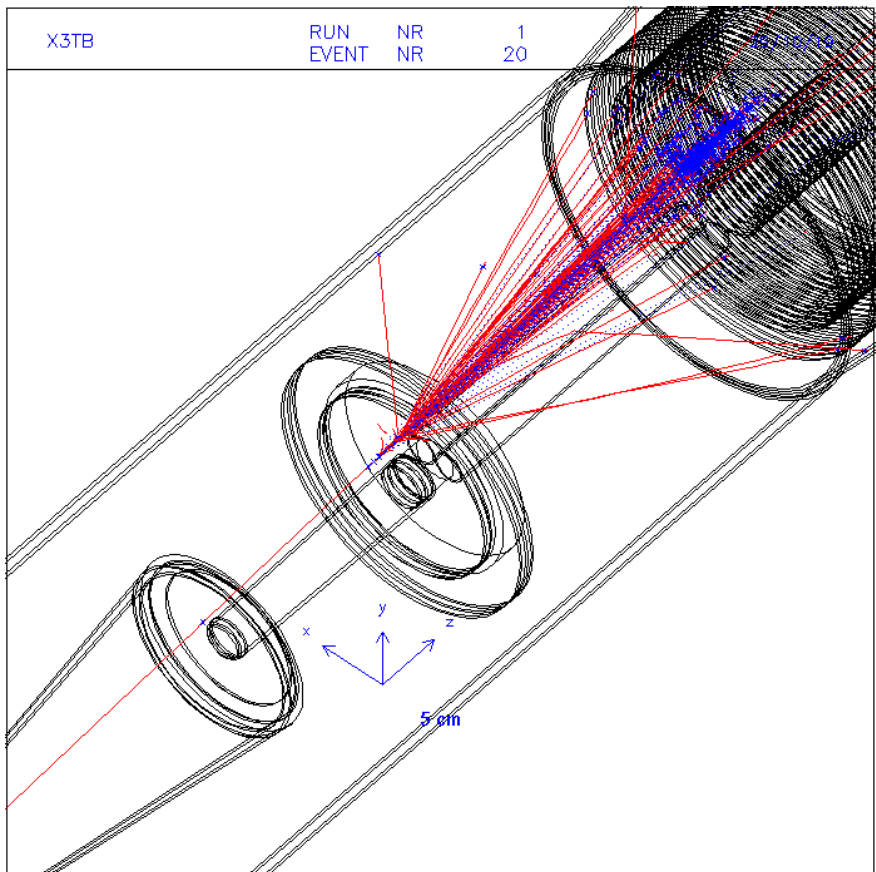
CONE beampipe, electron impact position

GEANT simulation precision is 0.1 MeV

Si wafer behind beam-pipe cone face, whatever material thickness,
Impact position is not effected by multiple scattering/fragmentation

➔ **Better than 1 μm**

50 GeV electron, shoot LumCal center $\theta = 40 \text{ mRad}$

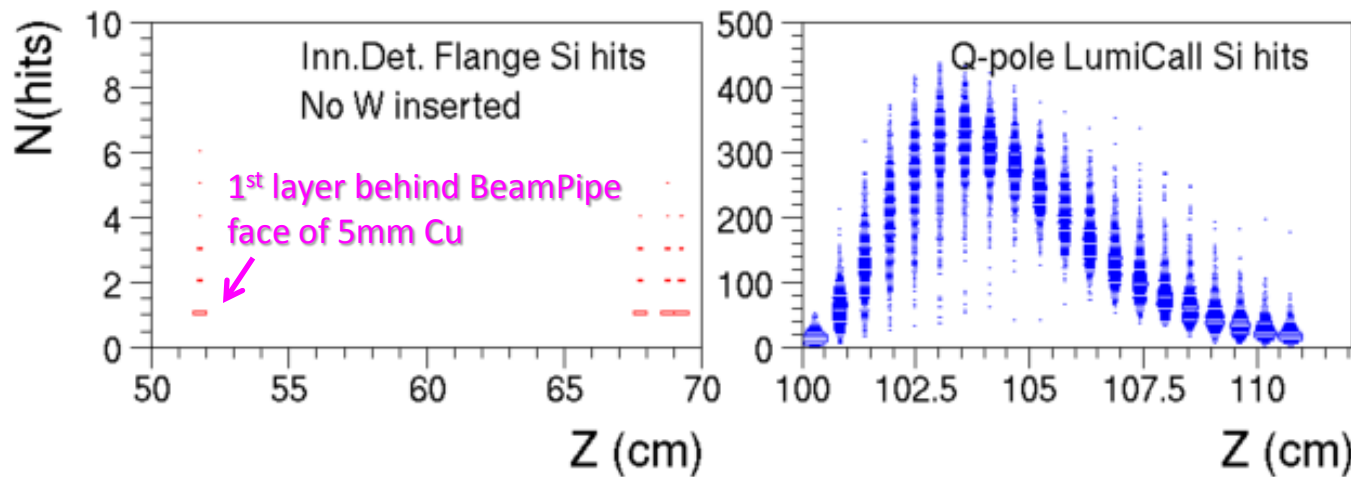


Precision on electron impact position

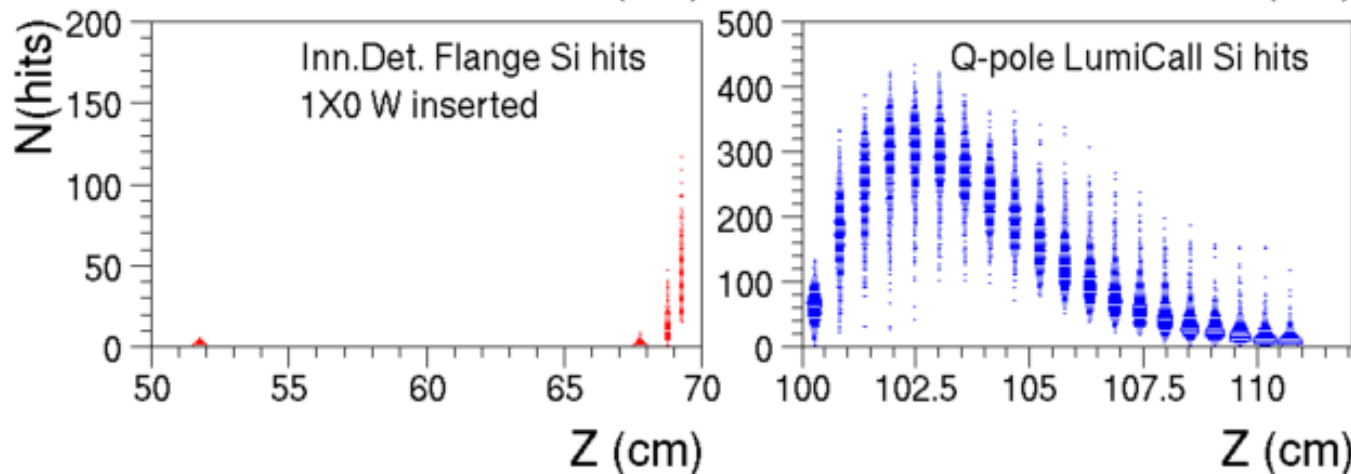
Compare Flange having two 1X0 Tungsten layers OR NOT

GEANT particles of 0.1MeV

Hits of charged shower secondaries on Si layers



← Flange has
NO Tungsten layers



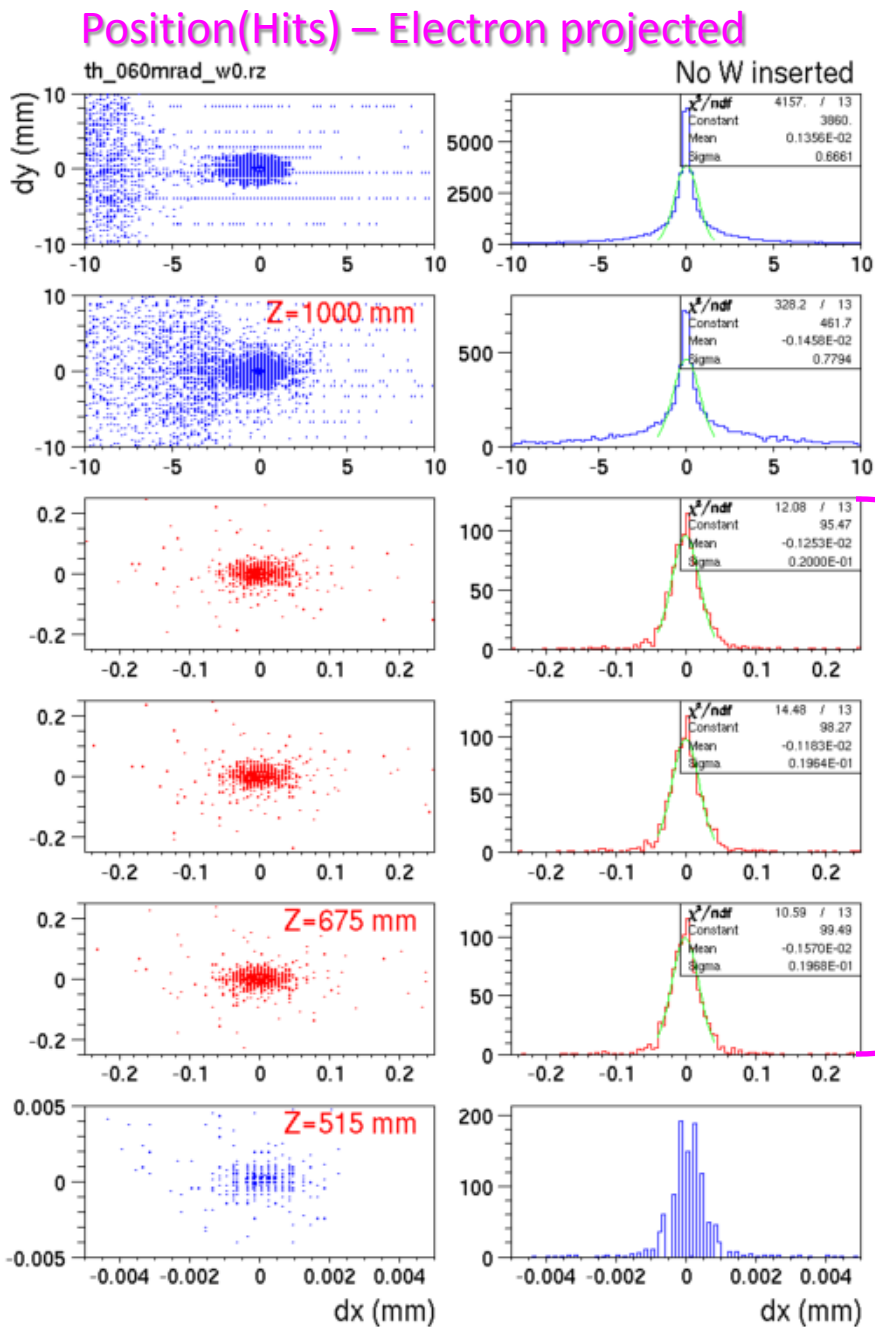
← Flange has 1X0
2 Tungsten layers

Spatial Resolution of piled up hits (50 GeV electrons)

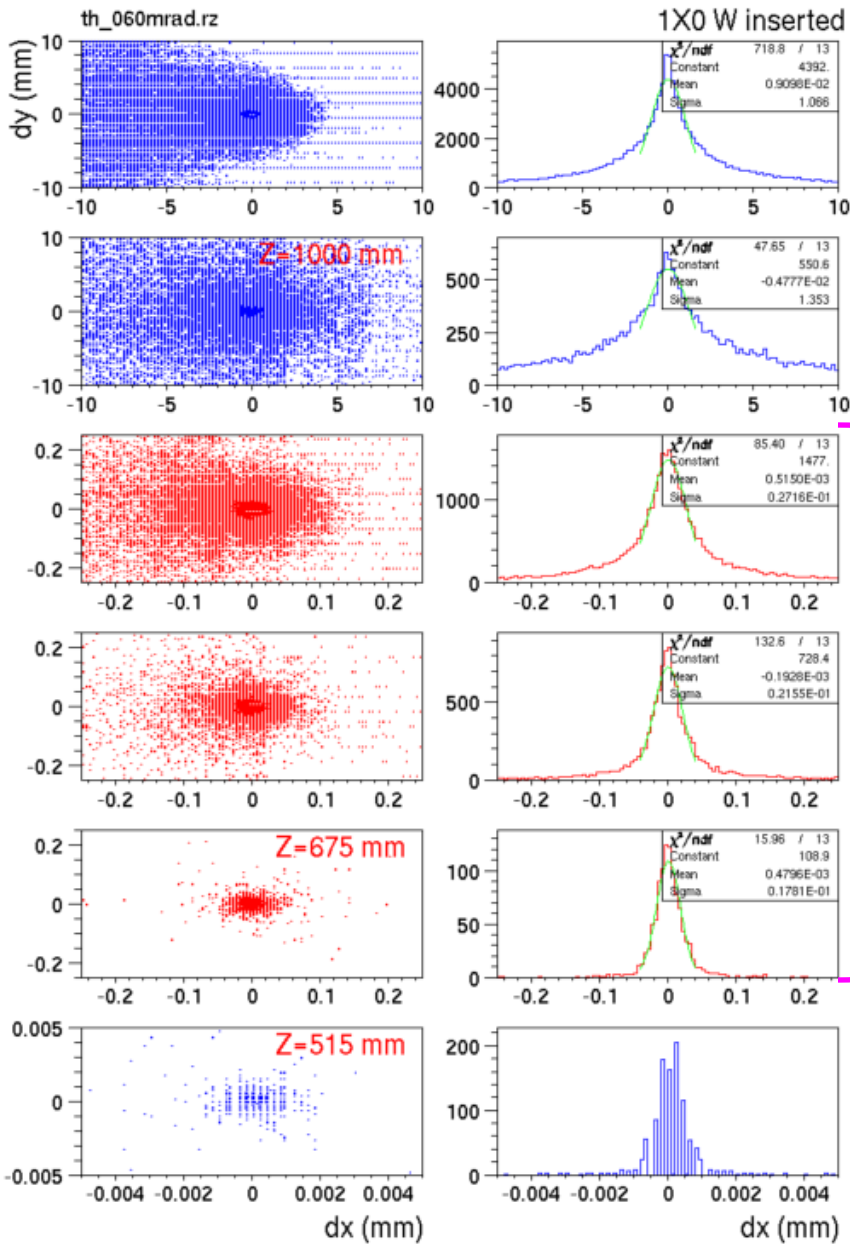
Front 2 Si-layers of Q-pole LumiCal
Pileup of shower ~ 1 mm resolution

Three Si layers at $Z > 670$ mm
NO Tungsten layers
Spatial resolution $\sim 20 \mu\text{m}$

1st Si layer behind Beampipe cone at $Z = 515$ mm
Hit deviation better than $1 \mu\text{m}$



Position(Hits) – Electron projected



Spatial Resolution of piled up hits (50 GeV electrons)

Front 2 Si-layers of Q-pole LumiCal
Pileup of shower ~ 1 mm resolution

Three Si layers at $Z > 670$ mm
Two 1X0 Tungsten layers behind Si wafers
Spatial resolution ~ 20 μm

1st Si layer behind Beampipe cone at $Z=515$ mm
Hit deviation better than 1 μm

TUBE beam-pipe, preshower in beampipe

$\text{acos}(.99) = 141.54 \text{ mRad}$ @Z=118 $\rightarrow r = 16.81 (= \tan Q * 118)$
 $\text{acos}(.992) = 126.58 \text{ mRad}$ @Z=118 $\rightarrow r = 15.02 \text{ mm}$
 $Q = 100 \text{ mRad}$ @Z=118 $\rightarrow r = 11.84 \text{ mm}$ @Z=153 $\rightarrow r = 15.35 \text{ mm}$

$\text{Acos}(.99) = .14154 \text{ rad}$
 $\text{Acos}(.992) = .1266 \text{ rad}$
 $\text{atan}(123.6/970) = .12678 \text{ rad}$

409 TbFe 5mm Fe
 Z=0~ 970 mm connecting to
 r= 12.34cm ~+.5cm, FE

TbOS 2mm scin
 Z=0~ 970 mm r= 12.39cm +.2cm

TbIS 2mm scin
 Z=0~ 970 mm r= 12.32cm +.2cm

Fling 10mm thick flange
 Z=520~530 mm
 r= 55~123.2 mm

Fwin window 2 mm
 Z=520~522
 r= 15.35~55 mm

BpSn Si octagon rmin =1.5451 cm
 Z=16 - 52.0 cm

419 FLSi Si deck **FSOi** SiW two layers
 Z=522~524 Deck=3.5mmW+2mmAir
 R= 15.5-55. mm R= 15.5-70. mm
 29.7-105 mrad 22.3-100.2 mrad @ Z= 696

Fend Flange 20mm
 Z=696 - 716
 r= 15.5~123.2 mm

Al dual tubes
 .5mm, .35 mm thick

Flange

100 mrad

401 InBPipe

InBP Inner Be pipe
 Z=0~118 mm,
 inner diameter 28 mm 0.5mm thick

InAl Inner Al pipe
 Z=118~500 mm,
 inner diameter 28 mm 0.5mm thick

Fpip flange pipe 1.5 mm thick
 Z= 522-716 mm
 at Z=512 r= 14 - 15.5 mm

OuBP outer Be pipe
 Z=0~115 mm
 inner radius 28/2+1 mm 0.35mm thick

OuAl outer Al pipe
 Z=0~115 mm
 inner r=28/2+1 mm, 0.35 mm thick

Z=115 mm
 Z=118 mm
 15 mm
 14 mm

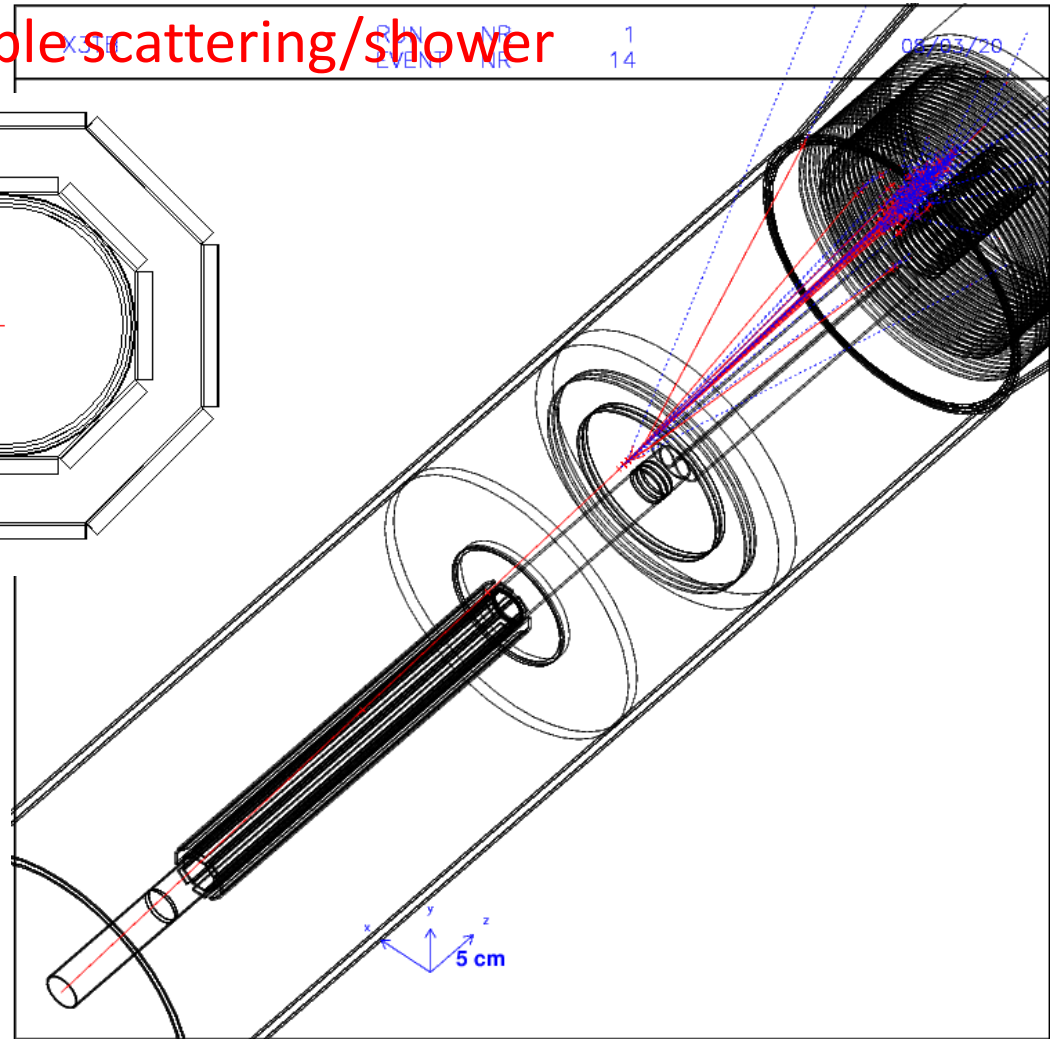
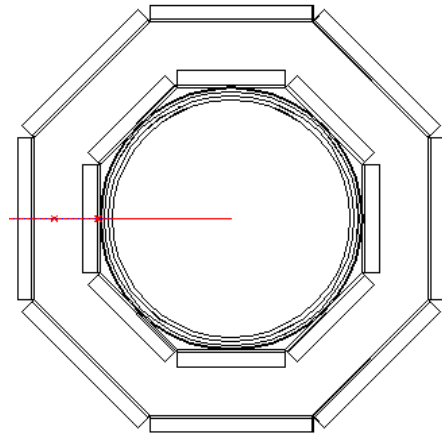
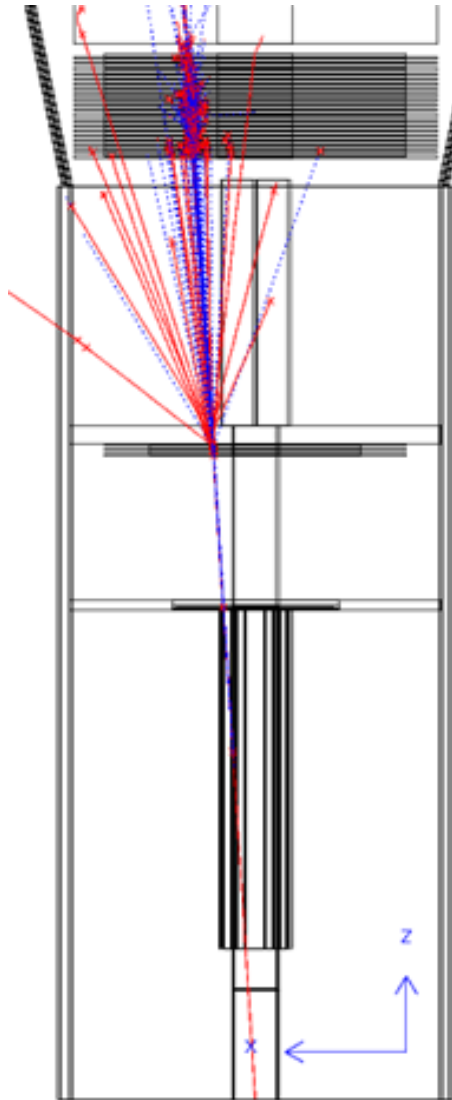
Z=520 mm

Fend Flange 20mm
 Z=696 - 716
 r= 15.5~123.2 mm

Si octagon wafers surrounding beampipe

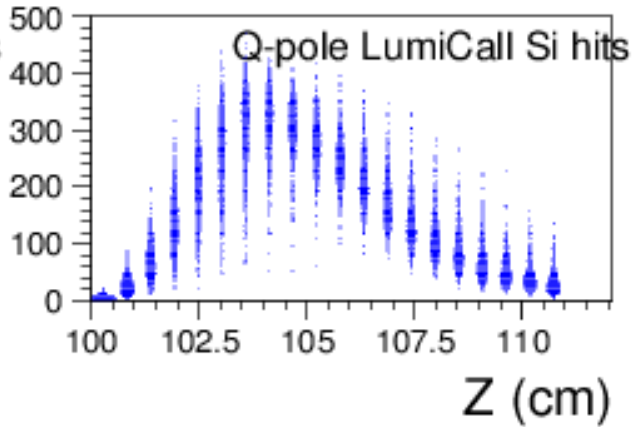
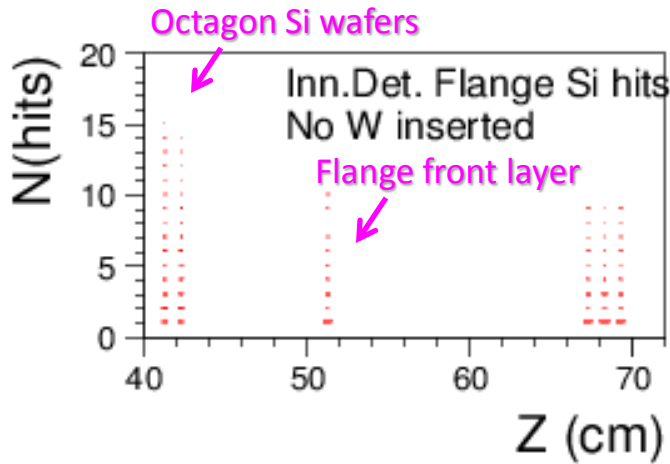
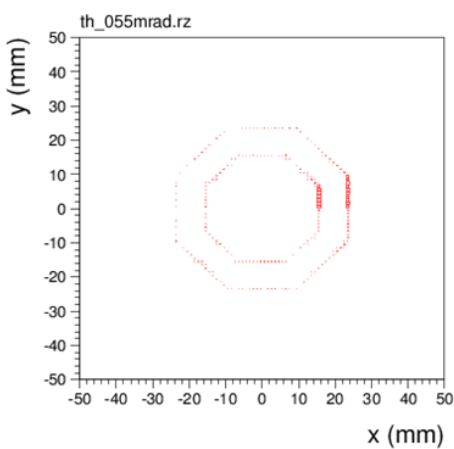
Si wafer attach to beampipe

→ Impact position w. minimum effect
multiple scattering/shower

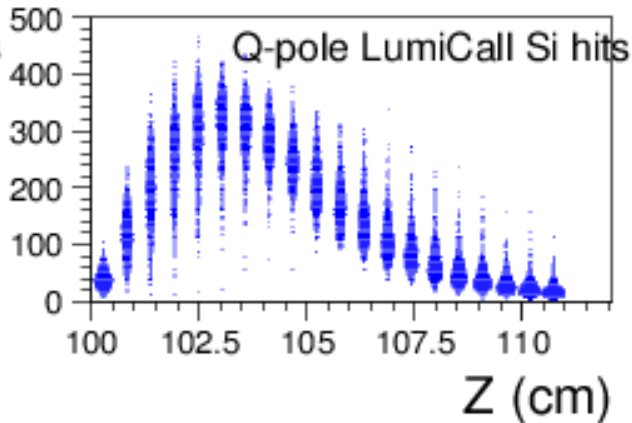
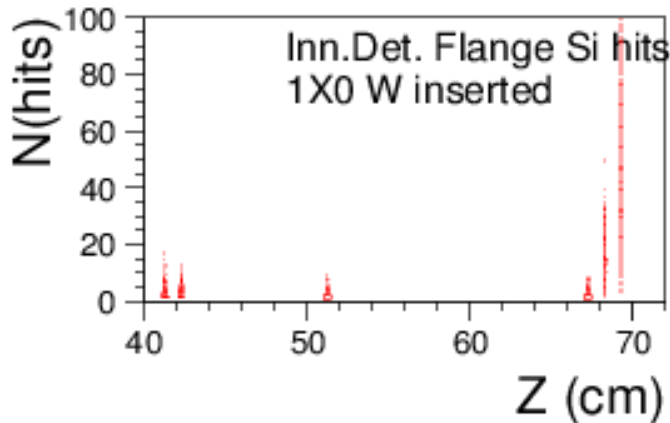


Precision on electron impact position

Hits of charged shower secondaries on Si layers

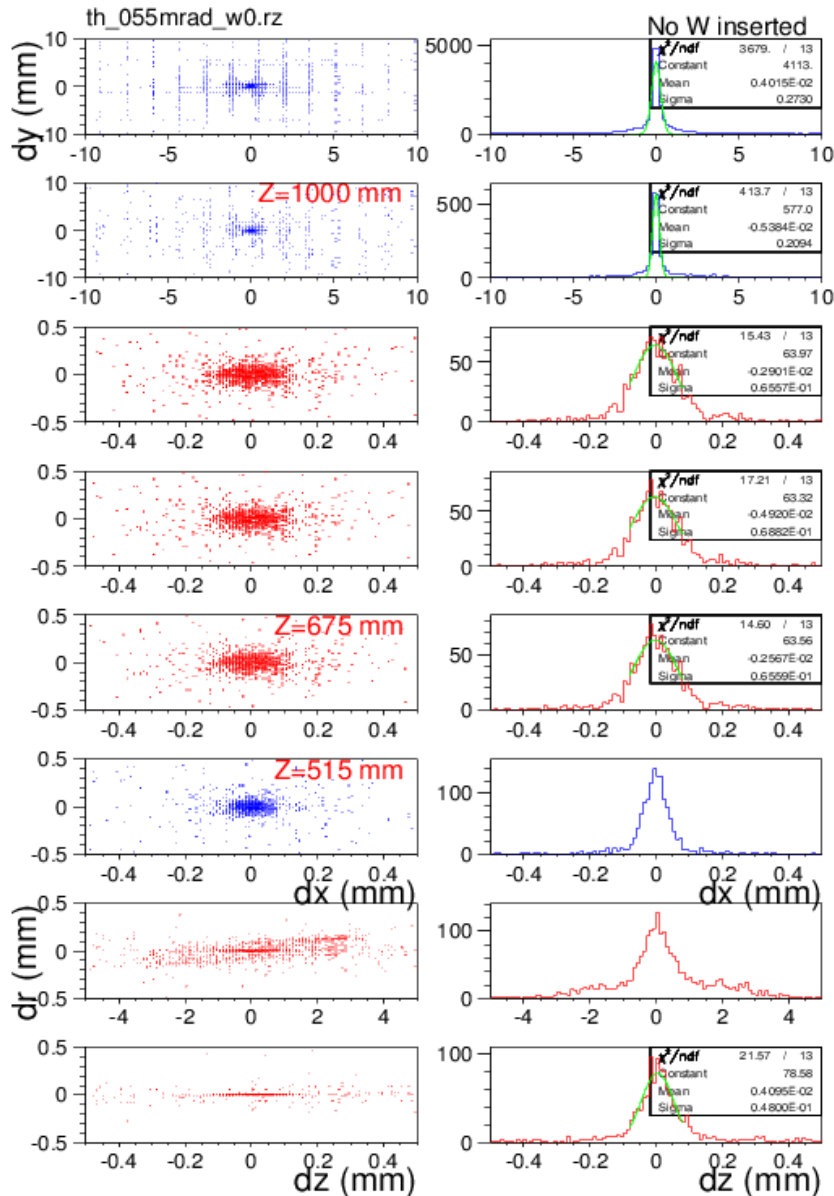


← Flange has NO Tungsten layers



← Flange has two 1X0 Tungsten layers

Position(Hits) – Electron shower



Piled up of shower hits (50 GeV electrons)

Front 2 Si-layers of Q-pole LumiCal
Pileup of shower ~ 1 mm resolution

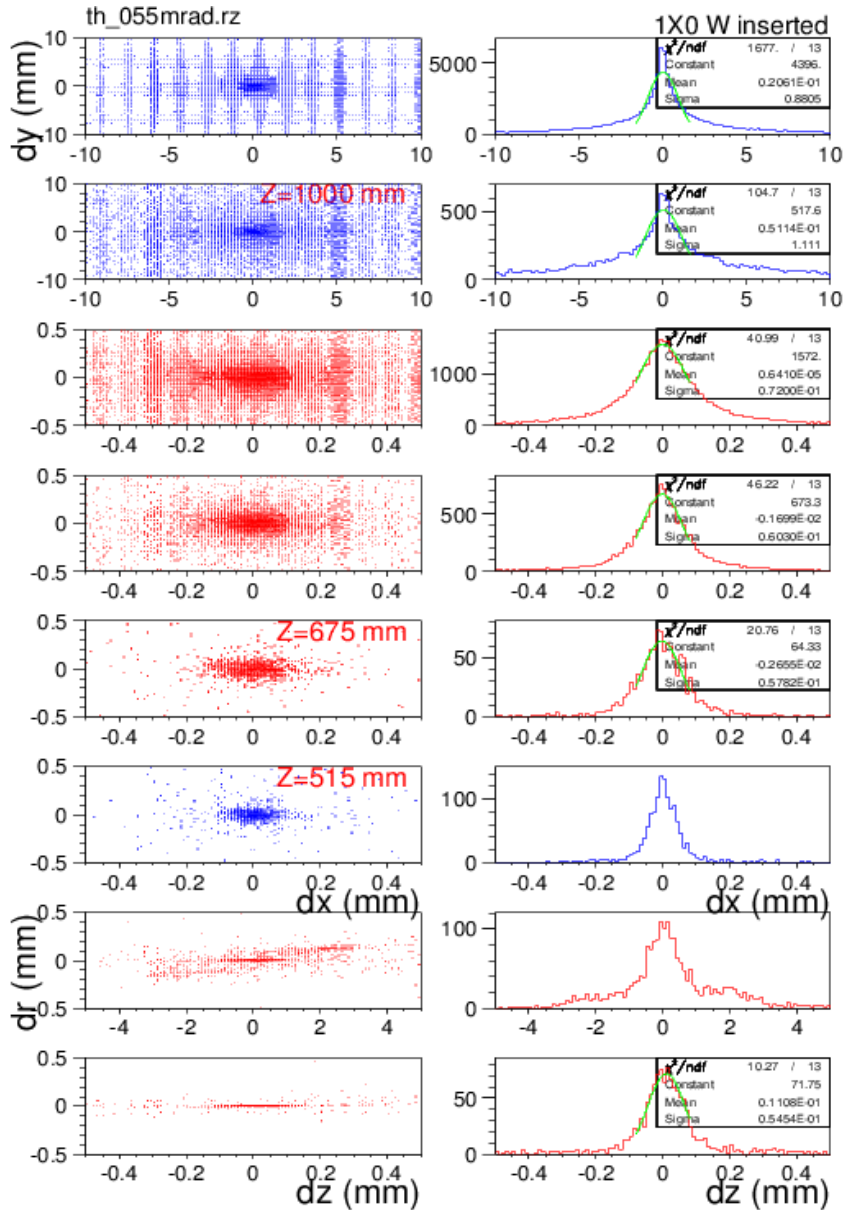
Three Si layers at $Z > 670$ mm
NO Tungsten layers $\sigma = 65$ μm

1st Si layer behind flange at $Z = 515$ mm

Octagon Si layers surrounding beampipe

1st layer $\sigma = 50$ μm

Position(Hits) – Electron shower



Piled up of shower hits (50 GeV electrons)

Front 2 Si-layers of Q-pole LumiCal
Pileup of shower ~ 1 mm resolution

Three Si layers at $Z > 670$ mm
Two 1X0 Tungsten layers
between Si wafers $\sigma = 60$ μm

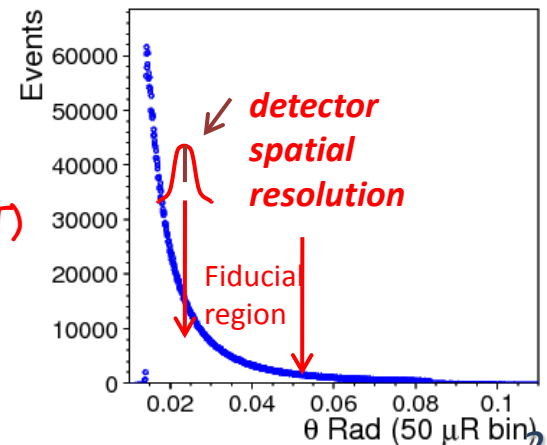
1st Si layer behind flange at $Z = 515$ mm

Octagon Si layers surrounding beampipe

1st layer $\sigma = 55$ μm
Due to Mult. Scattering

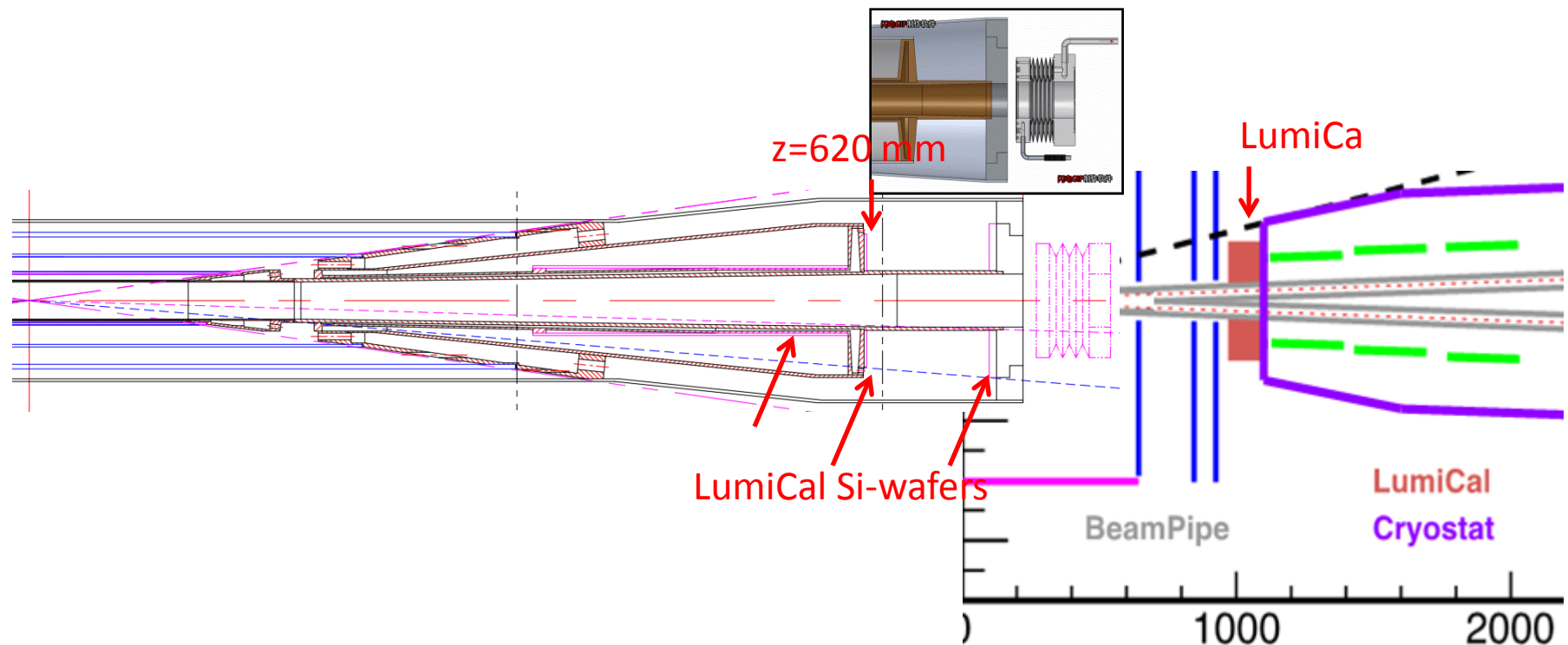
GEANT simulation summary

- Intrinsic spatial resolution scattered by multiple scattering, bremsstrahlung
- Luminosity $\delta L/L = 10^{-4}$, $\theta_{\min} = 30$ mRad
 $\delta L/L \sim 2 \delta\theta/\theta_{\min}$ for : $\delta\theta = 1.5 \mu\text{Rad}$
@ $z = 0.5\text{m}$, $dr = 0.75\mu\text{m}$; $dz = dr/\tan(.03) = 25\mu\text{m}$
- Electron traversing 1mm thick Al beampipe @30 mRad, $z=0.5\text{m}$, dz in beampipe = 33 mm
GEANT multiple scattering **RMS = 50 μm**
- $\delta L/L$ is the “error on the mean” off the fiducial edge
 1. analytic on Multi. Scattering (GEANT)
 2. detector resolution spectrum on fiducial edge

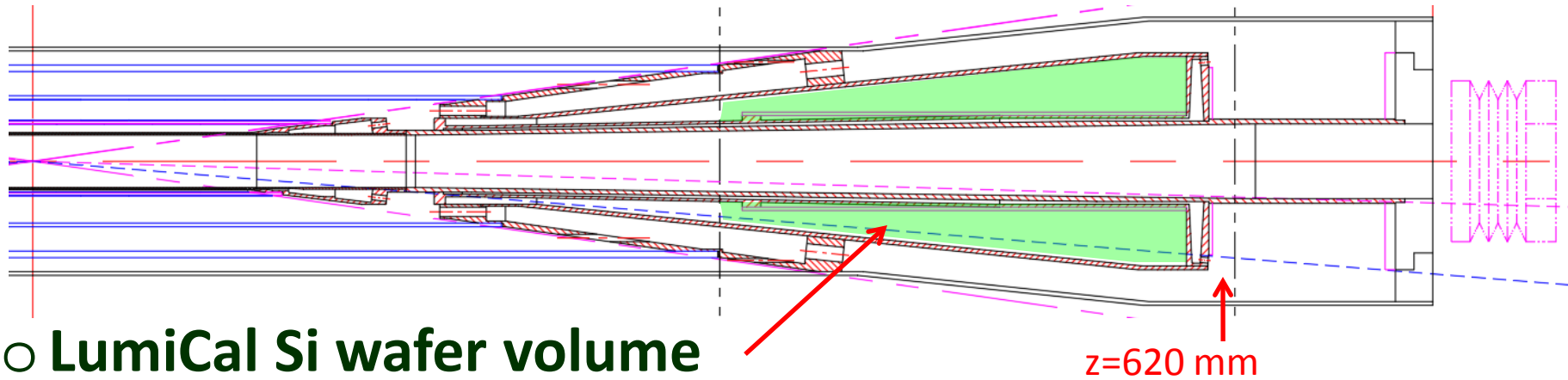


Detector options

- Silicon wafer on beampipe
- Calo for beam electron/gamma ID



LumiCal Si-wafer option



○ LumiCal Si wafer volume

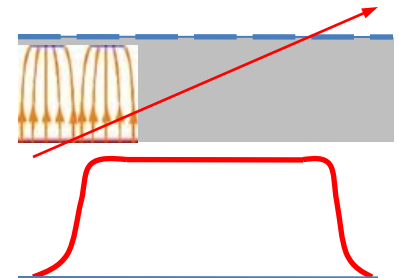
round beampipe $\phi = 28$ mm
 $\theta = 30$ mRad @ $z = 500$ mm

○ Si wafer option:

binary strip, pitch in z ,
resolution for $25 \mu\text{m} = \text{pitch}/\sqrt{12} \rightarrow \text{pitch} = 86 \mu\text{m}$
Multi.scattering ($50 \mu\text{m}$) is narrower, can be differentiated

Assuming Si strip $300 \mu\text{m}$ thick, ADC readout, pitch = $100 \mu\text{m}$, resolution by the fraction of entrance strip (low z)

\rightarrow fire 100 strips @ 30 mRad \leftarrow rather extreme for Si strip
resolution by charge sharing on the edge strip

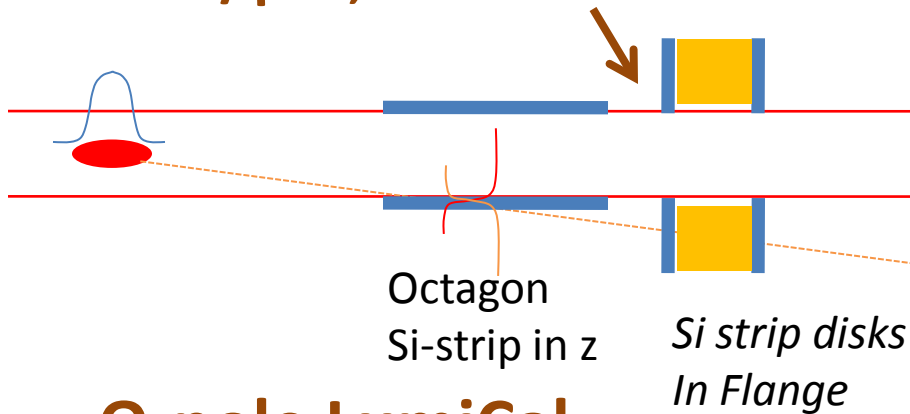


LumiCal Calo option

○ Calo options

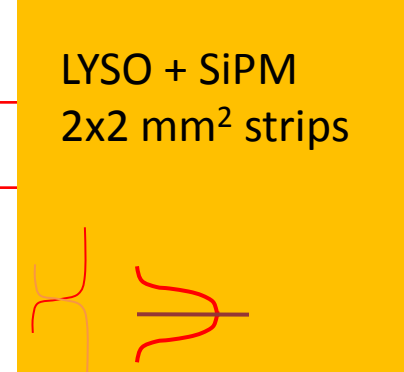
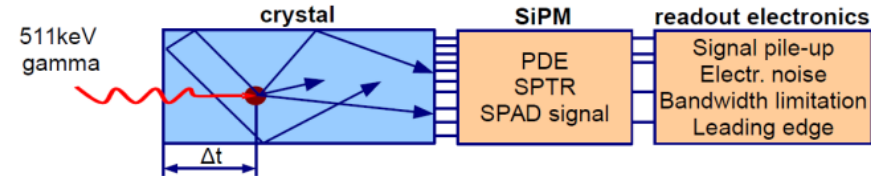
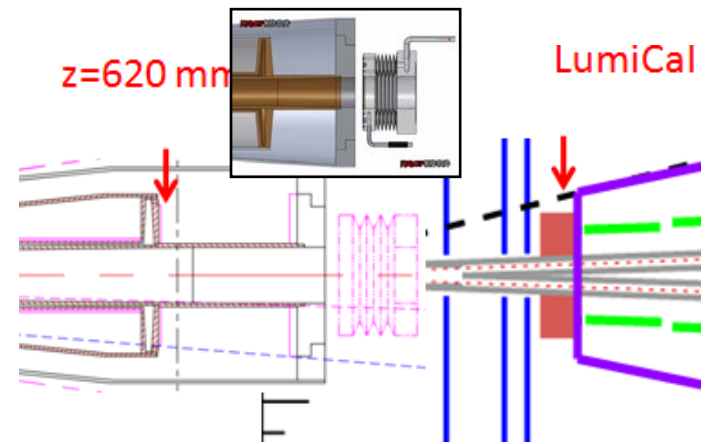
spatial resolution is not good
 LYSO + SiPM is compact
 minimize space for electronics

○ In the flange, as preshower front wafer disk (20 μ m) + 50 mm LYSO for e/ γ ID, NLO Bhabha etc



○ Q-pole LumiCal

front wafer disk (1 mm) + 100 mm LYSO
 for Bhabha beam electron EM shower



Far-forward tagger

Bhabha scattered electrons

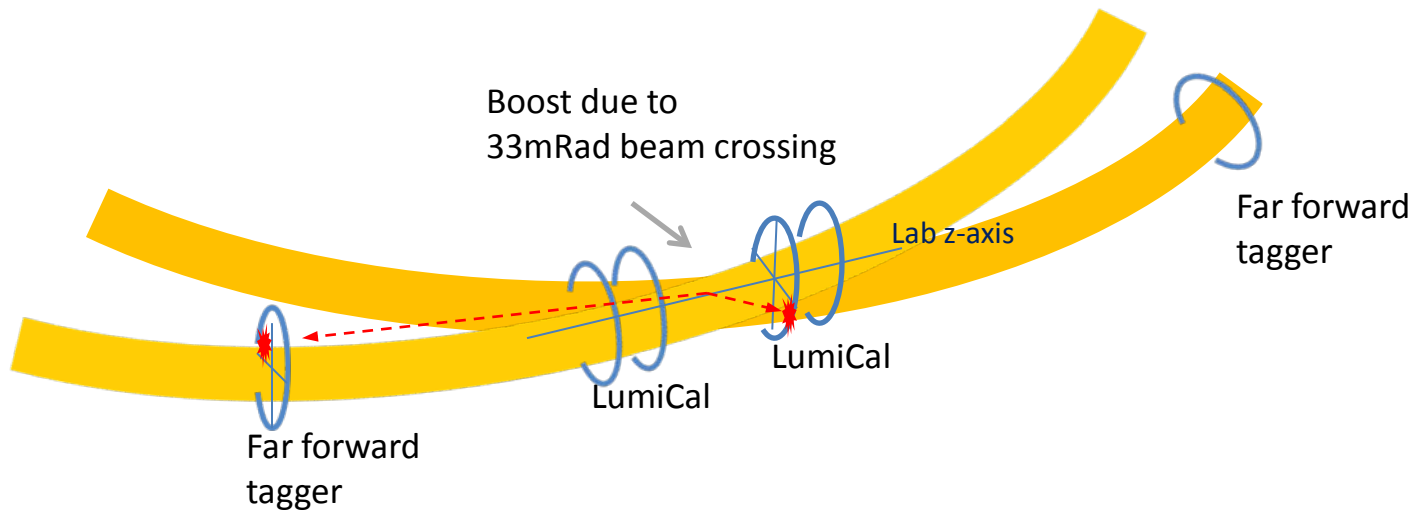
Symmetric to out-going beam-pipe, NOT the LAB frame

→ hit @ +x Lab frame : ϑ_{cms} is 16.5 mRad lower

→ LumiCal @ Lab +x region is **VERY HOT** by low ϑ beam electrons
tag Bhabha electrons by far-forward tagger
back-to-back in ϑ/φ to LumiCal hit

Detector option:

LYSO+SiPM in a ring, slide to position



Conclusion

- Bhabha feasibility studied for luminosity of 10^{-4}
 - X-section matches to $Z(qq)$ pole
 - Spatial resolution with Si-wafer in z , $\sim 25 \mu\text{m}$
 - LYSO + SiPM for Calo, compact in space for electronics
- Continue on prototyping of Detectors and Electronics